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Concl'd

59. The method of fabricating a semiconductor device in accordance with 44,  
wherein said laser annealing is performed by applying a laser beam in the form of  
sheet.

REMARKS

Claims 44-59 are pending in this application. The claims represent claims 45,  
46, 48-56, 60 and 73-76 which were cancelled in the parent application. No new matter  
is contained in the amendments.

Please charge any fee deficiency or credit any overpayment to Deposit Account  
No. 01-2300.

Respectfully submitted,

  
Rustan J. Hill  
Registration No. 37,351

ARENT FOX KINTNER PLOTKIN & KAHN, PLLC  
1050 Connecticut Avenue, N.W.,  
Suite 600  
Washington, D.C. 20036-5339  
Tel: (202) 857-6000  
Fax: (202) 638-4810